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Dong et al.(10) **Pub. No.: US 2017/0199436 A1**(43) **Pub. Date: Jul. 13, 2017**(54) **DISPLAY SUBSTRATE AND
MANUFACTURING METHOD THEREOF,
LIQUID CRYSTAL CELL AS WELL AS
DISPLAY**(71) Applicants: **Boe Technology Group Co., Ltd.**,
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Huang**, Beijing (CN); **Xing Qin**,
Beijing (CN); **Zhinan Zhang**, Beijing
(CN); **Xiuliang Wang**, Beijing (CN)(21) Appl. No.: **15/217,418**(22) Filed: **Jul. 22, 2016**(30) **Foreign Application Priority Data**

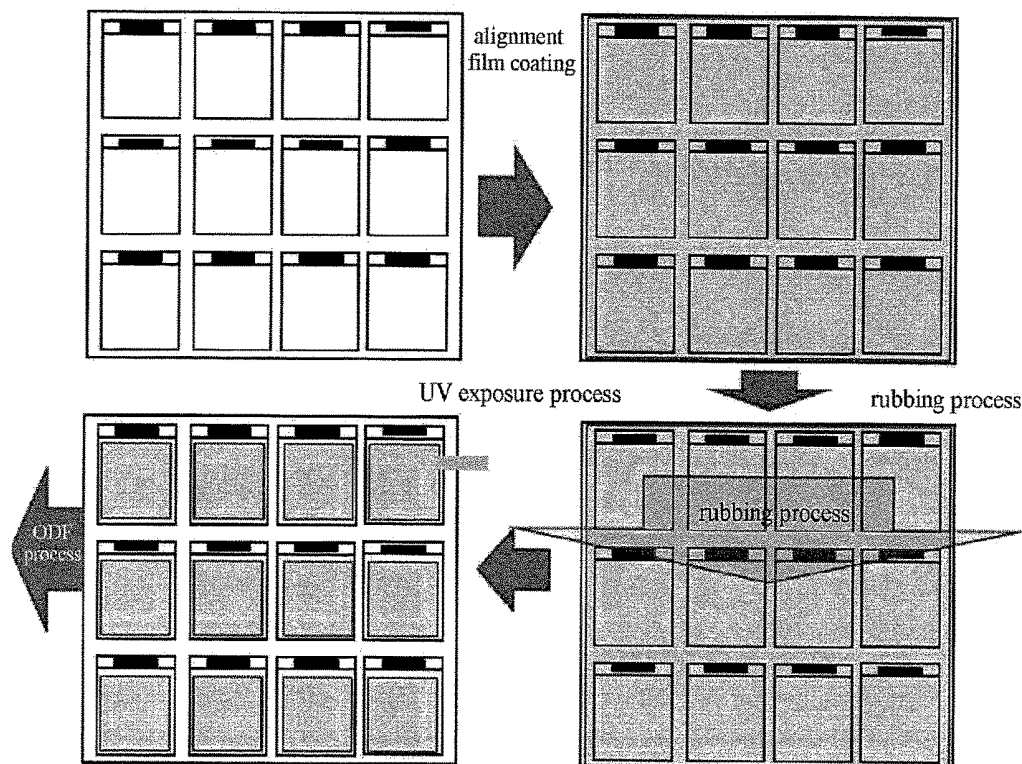
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(57)

ABSTRACT

The present application discloses a method for manufacturing a display substrate. The method comprises: coating all regions of a base substrate with an alignment film; performing a rubbing process on the base substrate coated with the alignment film; and removing the alignment film outside a display region of the base substrate by a photolithography process so as to retain only the alignment film in the display region. The present application further discloses a display substrate manufactured by such a manufacturing method, as well as a liquid crystal cell and a display comprising such a display substrate.



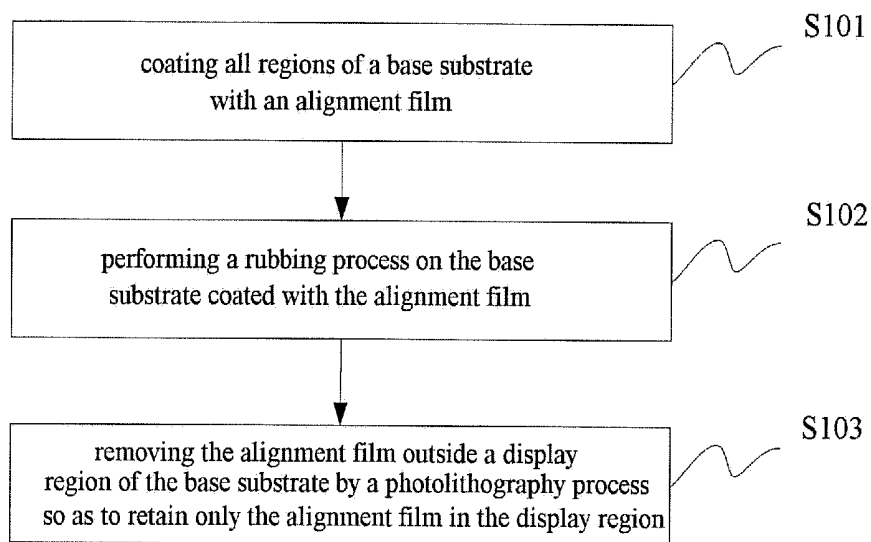


Fig. 1

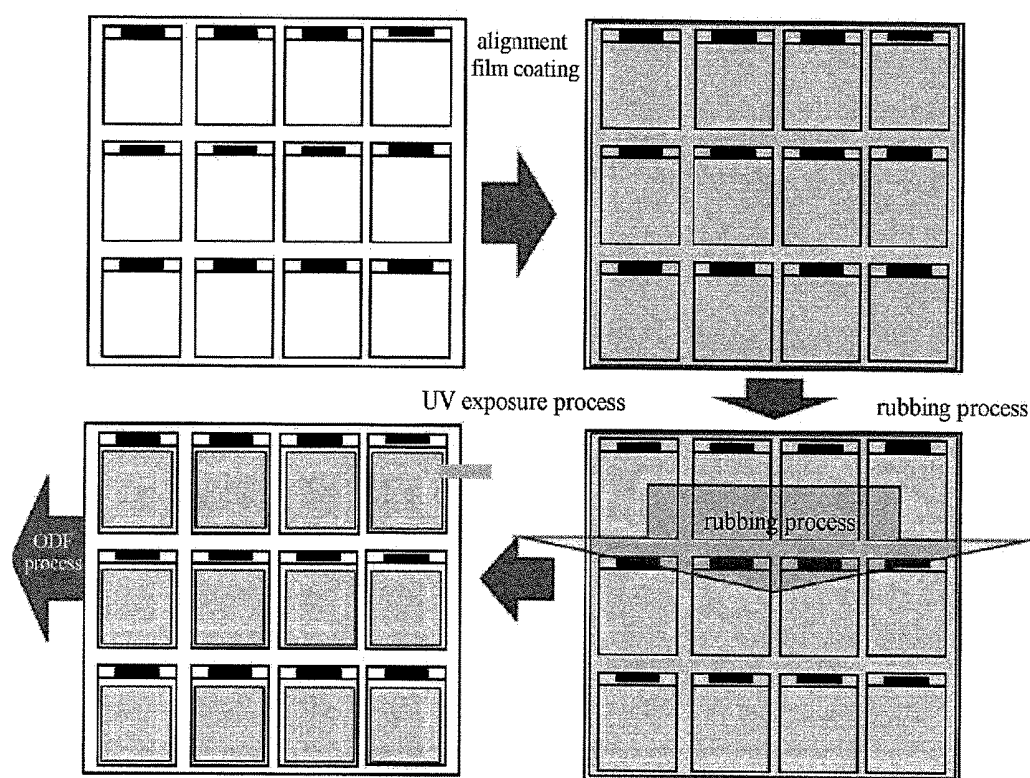


Fig. 2

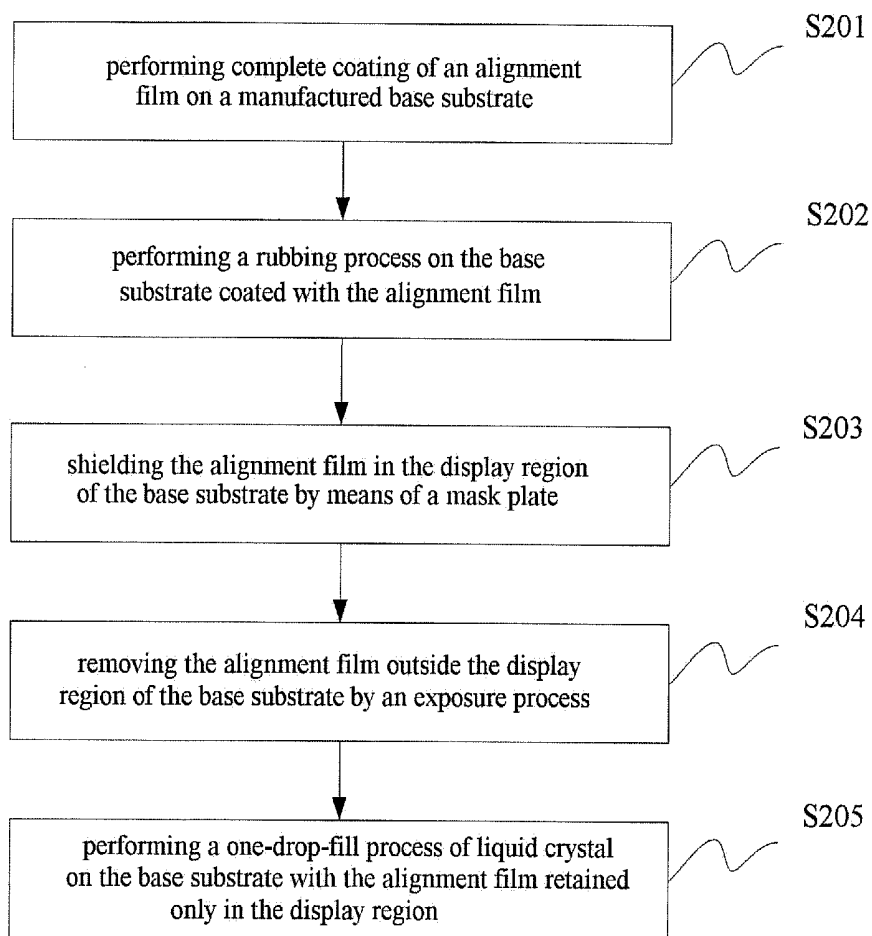


Fig. 3

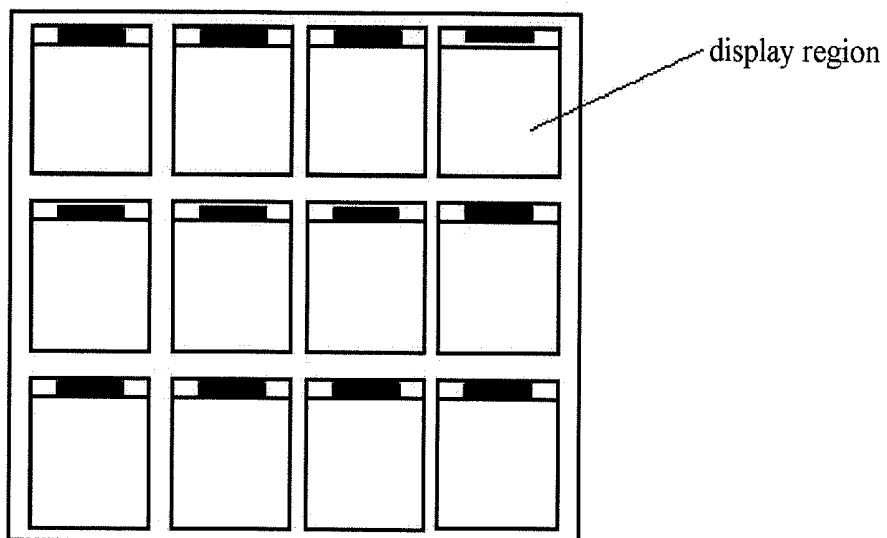


Fig. 4

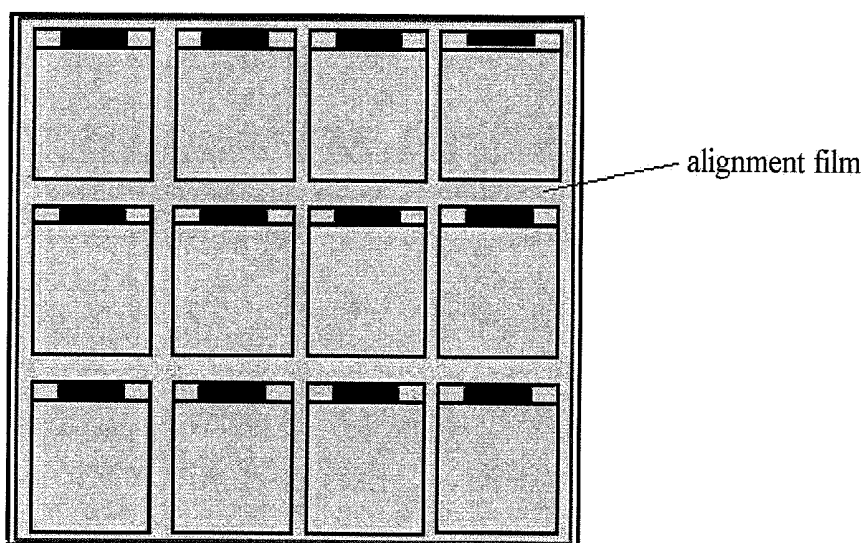


Fig. 5

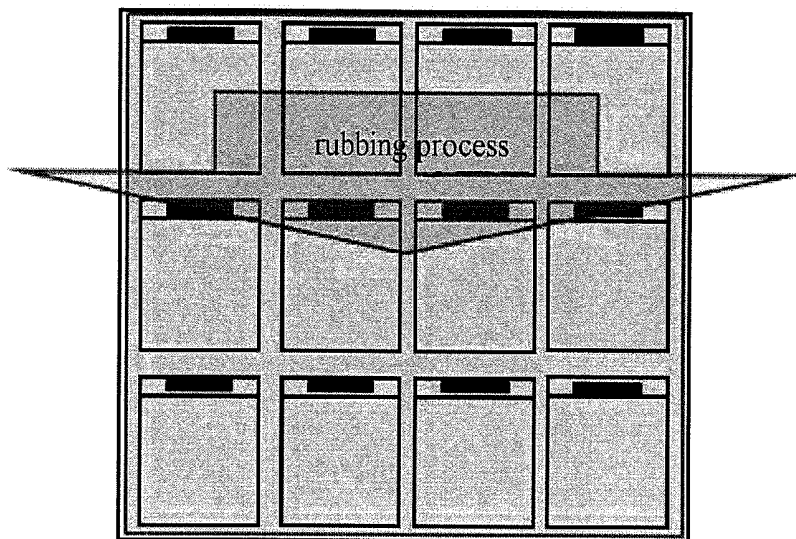


Fig. 6

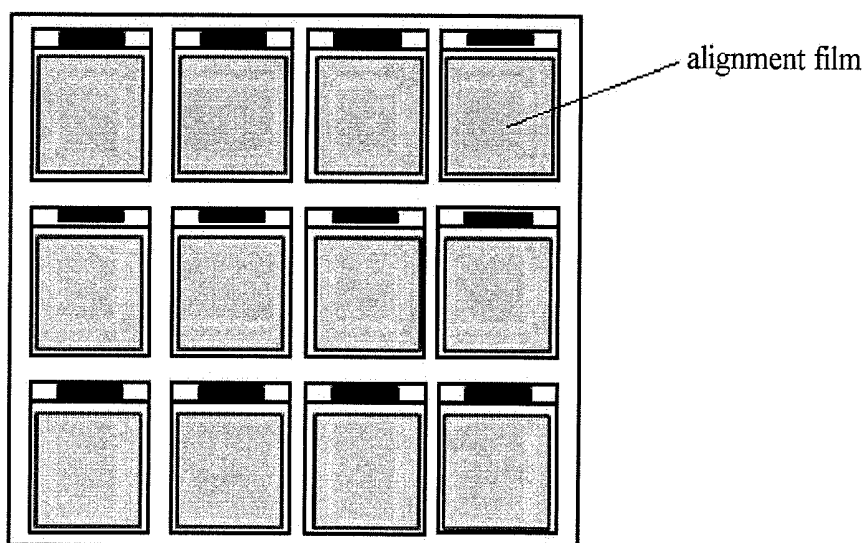


Fig. 7

**DISPLAY SUBSTRATE AND
MANUFACTURING METHOD THEREOF,
LIQUID CRYSTAL CELL AS WELL AS
DISPLAY**

**CROSS REFERENCE TO RELATED
APPLICATIONS**

[0001] The present application claims the benefit of Chinese patent application No. 201610008826.1 filed on Jan. 7, 2016, which is incorporated by reference in its entirety herein.

FIELD

[0002] The present application relates to the technical field of display, and specifically to a display substrate and a manufacturing method thereof, a liquid crystal cell as well as a display.

BACKGROUND ART

[0003] Rubbing Ghost Mura is a very serious quality problem in the existing process for a thin film transistor (TFT). It not only severely influences the image quality of products and the yield thereof, but also results in a low detection rate for inferior products, which easily gives rise to missed detection and causes huge waste of resources and materials in the back end accompanied by serious quality problems. The root cause for the problem of poor quality can be construed as follows. Since edges of a glass substrate have binding lines, during a rubbing process, when the rubbing proceeds to a connection position, friction cloth will generate an electrostatic difference as it contacts different surface mediums (including ITO, PVX and alignment film), and thus the fabric direction or the like of the cloth will be changed. In this case, unfavorable alignment abnormality will occur at the end of the rubbing, which is called Ghost Mura.

SUMMARY

[0004] Embodiments of the present application provide a display substrate and a manufacturing method thereof, a liquid crystal cell as well as a display, so as to at least partially alleviate or eliminate Ghost Mura. Besides, with such a display substrate and a manufacturing method thereof, a liquid crystal cell as well as a display, defects of an alignment film such as printing offset, edge unevenness and film thickness unevenness can all be avoided completely. Thereby image quality characteristics of a liquid crystal display device can be improved.

[0005] The embodiments of the present application provide a method for manufacturing a display substrate, comprising: coating all regions of a base substrate with an alignment film; performing a rubbing process on the base substrate coated with the alignment film; and removing the alignment film outside a display region of the base substrate by a photolithography process so as to retain only the alignment film in the display region.

[0006] According to this method, complete coating of an alignment film is performed on a manufactured base substrate, and then a rubbing process is performed. In this case, since what the friction cloth contacts is all alignment films, there is no electrostatic difference, and thereby Ghost Mura is effectively improved. Besides, defects of the alignment film such as printing offset, edge unevenness and film

thickness unevenness can all be avoided. Therefore, the image quality characteristics of the liquid crystal display device are improved.

[0007] Specifically, the step of removing the alignment film outside a display region of the base substrate by a photolithography process so as to retain only the alignment film in the display region comprises: shielding the alignment film in the display region of the base substrate by a mask plate; and removing the alignment film outside the display region of the base substrate by an exposure process.

[0008] Specifically, the base substrate is an array substrate or a color filter substrate.

[0009] Specifically, the exposure process is performed by ultraviolet (UV) light.

[0010] Specifically, the UV light has a wavelength of 146 nm~365 nm.

[0011] Specifically, a distance between the mask plate and the base substrate is smaller than or equal to 50 μm .

[0012] Specifically, the method further comprises: performing a one-drop-fill (ODF) process of liquid crystal on the base substrate with the alignment film retained only in the display region.

[0013] The embodiments of the present application further provide a display substrate, which display substrate is manufactured by the method provided in the above embodiments of the present application.

[0014] Specifically, the display substrate is an array substrate or a color filter substrate.

[0015] The embodiments of the present application further provide a liquid crystal cell, comprising an array substrate and a color filter substrate, wherein at least one of the array substrate and the color filter substrate is manufactured by the method provided in the above embodiments of the present application.

[0016] The embodiments of the present application further provide a display, comprising the liquid crystal cell provided in the above embodiments of the present application.

BRIEF DESCRIPTION OF DRAWINGS

[0017] FIG. 1 is a schematic flow chart illustrating a method for manufacturing a display substrate as provided in the embodiments of the present application;

[0018] FIG. 2 is a schematic principle view illustrating a method for manufacturing a display substrate as provided in the embodiments of the present application;

[0019] FIG. 3 is a schematic flow chart illustrating another method for manufacturing a display substrate as provided in the embodiments of the present application;

[0020] FIG. 4 is a schematic structural view of a base substrate comprising a plurality of rectangular display regions as provided in the embodiments of the present application;

[0021] FIG. 5 is a schematic structural view of a base substrate after complete coating of an alignment film as provided in the embodiments of the present application;

[0022] FIG. 6 is a schematic view for performing a rubbing process on a substrate coated with an alignment film as provided in the embodiments of the present application; and

[0023] FIG. 7 is a schematic structural view of a base substrate with an alignment film retained only in the display region as provided in the embodiments of the present application.

DETAILED DESCRIPTION OF EMBODIMENTS

[0024] The embodiments of the present application provide a display substrate and a manufacturing method thereof, a liquid crystal cell as well as a display, so as to at least partially alleviate or eliminate Ghost Mura. Besides, with such a display substrate and a manufacturing method thereof, a liquid crystal cell as well as a display, defects of an alignment film such as printing offset, edge unevenness and film thickness unevenness can all be avoided completely. Thereby image quality characteristics of a liquid crystal display device can be improved.

[0025] Referring to FIG. 1, the embodiments of the present application provide a method for manufacturing a display substrate comprising steps as follows. **S101**, coating all regions of a base substrate with an alignment film. It should be noted that before all regions are coated with the alignment film, conventional operations such as printing, pre-curing and main curing can also be performed on an alignment material to be used (e.g., polyimide PI). **S102**, performing a rubbing process on the base substrate coated with the alignment film. **S103**, removing the alignment film outside a display region of the base substrate by a photolithography process so as to retain only the alignment film in the display region.

[0026] Specifically, the above step **S103** can comprise the following sub-steps: shielding the alignment film in the display region of the base substrate by a mask plate; and removing the alignment film outside the display region of the base substrate by an exposure process.

[0027] Specifically, the base substrate is an array substrate or a color filter substrate.

[0028] In other words, the method provided in the embodiments of the present application can be used for manufacturing both an array substrate and a color filter substrate.

[0029] Specifically, the exposure process is performed by ultraviolet UV light.

[0030] In addition, specifically, the mask plate to be used should also ensure that the alignment material (e.g., polyimide PI) and a sealant do not overlay each other.

[0031] Specifically, the UV light has a wavelength of 146 nm~365 nm. Of course, it can also have other wavelengths.

[0032] Specifically, a distance between the mask plate and the base substrate is smaller than or equal to 50 μm .

[0033] Specifically, the method further comprises: performing a one-drop-fill process of liquid crystal on the base substrate with the alignment film retained only in the display region.

[0034] The embodiments of the present application provide a new substrate manufacturing process so as to achieve normal binding lines while improving Ghost Mura. Referring to FIG. 2, complete coating of an alignment film is performed on an array substrate and a color filter substrate which have already been manufactured (the alignment film for coating is indicated by a grey shadow in FIG. 2), and then a rubbing process is performed. In this case, there is no electrostatic difference since what the friction cloth contacts is all alignment films, and thereby Ghost Mura is effectively improved. After the rubbing process is accomplished, the alignment film outside a display region of the base substrate is removed by a photolithography process, so as to retain only the alignment film in the display region. Specifically, the mask plate is arranged on the alignment film such that the mask plate shields the alignment film in the display region; the alignment film outside the display region of the

substrate is removed by UV exposure; and then subsequent processes such as one-drop-fill are performed. In this way, Ghost Mura can be improved effectively, and defects of the alignment film such as printing offset, edge unevenness and film thickness unevenness can also be avoided. Thereby image quality characteristics of the liquid crystal display device are improved.

[0035] In other words, referring to FIG. 3, the method for manufacturing a display substrate as provided in the embodiments of the present application can comprise steps as follows. **S201**, performing complete coating of an alignment film on a manufactured base substrate. As shown in FIG. 4, the manufactured base substrate comprises a plurality of rectangular display regions. **S202**, performing a rubbing process on the base substrate coated with the alignment film. As shown in FIG. 5, the alignment film for coating is indicated by a grey shadow. FIG. 6 shows a procedure of performing a rubbing process on a substrate coated with an alignment film. **S203**, shielding the alignment film in the display region of the base substrate by a mask plate. **S204**, removing the alignment film outside the display region of the base substrate by an exposure process. **S205**, performing a one-drop-fill process of liquid crystal on the base substrate with the alignment film retained only in the display region.

[0036] Specifically, as shown in FIG. 7, the alignment film is retained in each display region.

[0037] The embodiments of the present application further provide a display substrate, which display substrate is manufactured by the method provided in the above embodiments of the present application.

[0038] Specifically, the display substrate is an array substrate or a color filter substrate.

[0039] The embodiments of the present application further provide a liquid crystal cell, comprising an array substrate and a color filter substrate, wherein at least one of the array substrate and the color filter substrate is manufactured by the method provided in the above embodiments of the present application.

[0040] The embodiments of the present application further provide a display, comprising the liquid crystal cell provided in the above embodiments of the present application.

[0041] To sum up, according to the embodiments of the present application, complete coating of an alignment film is performed on an array substrate and a color filter substrate which have already been manufactured, and then a rubbing process is performed. Since what the friction cloth contacts is all alignment films, there is no electrostatic difference, and thereby Ghost Mura is effectively improved. After the rubbing process is accomplished, the alignment film outside a display region of the base substrate is removed by a photolithography process so as to retain only the alignment film in the display region. Specifically, the mask plate is arranged on the alignment film such that the mask plate shields the alignment film in the display region; the alignment film outside the display region of the substrate is removed by UV exposure; and then subsequent processes such as one-drop-fill are performed. In this way, Ghost Mura can be improved effectively, and defects of the alignment film such as printing offset, edge unevenness and film thickness unevenness can also be avoided. Thereby image quality characteristics of the liquid crystal display device are improved.

[0042] Obviously, those skilled in the art can make various modifications and variations to the present application without deviating from the spirits and scopes of the present

application. Thus if the modifications and variations to the present application fall within the scopes of the claims of the present application and the equivalent techniques thereof, the present application is intended to include them too.

1. A method for manufacturing a display substrate, comprising:

coating all regions of a base substrate with an alignment film;

performing a rubbing process on the base substrate coated with the alignment film; and

removing the alignment film outside a display region of the base substrate by a photolithography process so as to retain only the alignment film in the display region.

2. The method according to claim 1, wherein the step of removing the alignment film outside the display region of the base substrate by the photolithography process so as to retain only the alignment film in the display region comprises:

shielding the alignment film in the display region of the base substrate by a mask plate; and

removing the alignment film outside the display region of the base substrate by an exposure process.

3. The method according to claim 1, wherein the base substrate is an array substrate or a color filter substrate.

4. The method according to claim 2, wherein the exposure process is performed by ultraviolet (UV) light.

5. The method according to claim 4, wherein the UV light has a wavelength of 146 nm~365 nm.

6. The method according to claim 2, wherein a distance between the mask plate and the base substrate is smaller than or equal to 50 μm .

7. The method according to claim 1, further comprising: performing a one-drop-fill process of liquid crystal on the base substrate with the alignment film retained only in the display region.

8. The method according to claim 7, wherein the step of removing the alignment film outside the display region of the base substrate by the photolithography process so as to retain only the alignment film in the display region comprises:

shielding the alignment film in the display region of the base substrate by a mask plate; and

removing the alignment film outside the display region of the base substrate by an exposure process.

9. The method according to claim 7, wherein the base substrate is an array substrate or a color filter substrate.

10. The method according to claim 8, wherein the exposure process is performed by ultraviolet (UV) light.

11. The method according to claim 10, wherein the UV light has a wavelength of 146 nm~365 nm.

12. The method according to claim 8, wherein a distance between the mask plate and the base substrate is smaller than or equal to 50 μm .

13. A display substrate manufactured by the method according to claim 1.

14. The display substrate according to claim 13, wherein the display substrate is an array substrate or a color filter substrate.

15. A liquid crystal cell comprising an array substrate and a color filter substrate, wherein at least one of the array substrate and the color filter substrate is manufactured by the method according to claim 1.

16. A display comprising the liquid crystal cell according to claim 15.

* * * * *

专利名称(译)	显示基板及其制造方法，液晶单元以及显示器		
公开(公告)号	US20170199436A1	公开(公告)日	2017-07-13
申请号	US15/217418	申请日	2016-07-22
[标]申请(专利权)人(译)	京东方科技集团股份有限公司 北京京东方光电科技有限公司		
申请(专利权)人(译)	京东方科技集团股份有限公司.		
当前申请(专利权)人(译)	京东方科技集团股份有限公司.		
[标]发明人	DONG TINGZE HUANG XUEJIAO QIN XING ZHANG ZHINAN WANG XIULIANG		
发明人	DONG, TINGZE HUANG, XUEJIAO QIN, XING ZHANG, ZHINAN WANG, XIULIANG		
IPC分类号	G02F1/1337 G02F1/1341		
CPC分类号	G02F1/133788 G02F2001/13415 G02F1/133784 G02F1/1341 G02F1/1333		
优先权	201610008826.1 2016-01-07 CN		
其他公开文献	US9740051		
外部链接	Espacenet USPTO		

摘要(译)

本申请公开了一种制造显示基板的方法。该方法包括：用取向膜涂覆基础基底的所有区域；在涂有取向膜的基底基板上进行摩擦处理；通过光刻工艺去除基础衬底的显示区域外的取向膜，以便仅在显示区域中保留取向膜。本申请还公开了通过这种制造方法制造的显示基板，以及液晶单元和包括这种显示基板的显示器。

